

**IN THE CLAIMS:**

Please amend the claims as follows:

Claim 1 (Currently Amended): A data pad region of a liquid crystal display panel, comprising:

a plurality of data lines vertically arranged at specified intervals;

a plurality of data pads respectively connected to the data lines;

at least one first side contact with a first area formed in each data pad, the data line being side-contacted with a conductive material in the first side contact; and

at least one second side contact with a second area formed in each data pad, the data line being side-contacted with the conductive material in the second side contact,

wherein the first side contact is positioned in a central portion of the data pad and a [[the]] first contact area contacted with the conductive material is larger than [[the]] a second area contacted with the conductive material.

Claim 2 (Original): The data pad region of claim 1, wherein the first side contact is positioned in a central portion of the data pad.

Claim 3 (Original): The data pad region of claim 2, wherein at least two second side contacts are respectively formed at one end of each data pad and at the other end of each data pad.

Claim 4 (Currently Amended): A method for fabricating a data pad region of a liquid crystal display panel, comprising:

forming a gate insulating layer, data lines and a passivation film in a data pad forming region of a substrate;

forming at least one first side contact hole with a first area at the central region of the data pad forming region and forming at least two second side contact holes with a second area respectively at both edges of the data pad forming region, ~~wherein the first area is larger than the second area;~~ and

forming at least one first side contact electrically connecting one of the data lines to a conductive layer at the first side contact hole and forming at least one second side contact electrically contacting the data line to the conductive layer at the second side contact hole by patterning a conductive material,

wherein the first side contact is positioned in a central portion of the data pad and a first contact area contacted with the conductive material is larger than a second contact area contacted with the conductive material.

Claim 5 (Original): The method of claim 4, wherein the passivation film is made of an organic material.

Claim 6 (Original): The method of claim 4, wherein the passivation film is made of BCB (benzocyclobutene).

Claim 7 (Original): The method of claim 4 , wherein the passivation film is formed as a triple deposition structure of SiNx film/BCB (benzocyclobutene) film/SiNx film.

Claim 8 (Original): The method of claim 4, wherein the data line is made of Mo.

Claim 9 (Original): The method of claim 4, wherein the data line is etched by dry-etching.

Claim 10 (Original): The method of claim 4, wherein the gate insulating layer is exposed at the bottom surfaces of the first side contact hole and the second side contact hole by dry-etching of the passivation film.

Claim 11 (Currently Amended): A data pad region of a liquid crystal display panel, comprising:

a substrate;

a gate insulating layer, data lines and a passivation film in a data pad forming region of the substrate, wherein the passivation film in the data pad forming region including at least one first side contact hole with a first area and at least one second side contact hole with a second area, wherein the first area is larger than the second area, the first side contact and the second contact being covered with conductive material; and

at least one first side contact electrically connecting one of the data lines to a conductive layer at the first side contact hole and at least one second side contact electrically connecting the data line to the conductive layer at the second side contact hole,

wherein the first side contact hole is positioned in a central portion of the data pad and at least two second side contact holes are respectively formed at one end of each data pad and at the other end of each data pad, a first contact area contacted with the conductive material is larger than a second contact area contacted with the conductive material.

Claim 12 (Original): The data pad region of claim 11, wherein the passivation film is made of an organic material.

Claim 13 (Original): The data pad region of claim 11, wherein the passivation film is made of BCB (benzocyclobutene).

Claim 14 (Original): The data pad region of claim 11, wherein the passivation film is formed as a triple deposition structure of SiNx film/BCB (benzocyclobutene) film/SiNx film.

Claim 15 (Original): The data pad region of claim 11, wherein the data line is made of Mo.

Claim 16 (Currently Amended): A liquid crystal display panel, comprising:  
a substrate having an image display region with unit pixels arranged in a matrix and a data pad region at the periphery of the image display region, wherein the data pad region includes:

a plurality of data lines vertically arranged at specified intervals;

a plurality of data pads respectively connected to the data lines;

at least one first side contact with a first area formed in each data pad, the data line being side-contacted with a conductive material in the first side contact; and

at least one second side contact with a second area formed in each data pad, wherein the first area is larger than the second area, the data line being side-contacted with the conductive material in the second side contact

wherein the first side contact is positioned in a central portion of the data pad and a first contact area contacted with the conductive material is larger than a second contact area contacted with the conductive material.

Claim 17 (New): The liquid crystal display panel of claim 16, wherein the conductive material includes a pixel electrode at unit pixel.